Supporting Information

Reverse Synthesis of Yolk-Shell Metal-Organic Frameworks

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Experimental Section

Materials

Zinc acetate dihydrate $(Zn(OAc)_2 \cdot 2H_2O,$ AR, Aladdin), Zinc nitrate hexahydrate($Zn(NO_3)_2 \cdot 6H_2O$, AR, Aladdin), Cobaltous Nitrate Hexahydrate (Co(NO₃)₂·6H₂O, AR, Aladdin), Cobalt(II) acetate tetrahydrate (Co(OAc)₂·4H₂O, AR, Aladdin), 2-Methylimidazole (HMIM, AR ,Adamas), Methanol (AR ,≥99.5%, GENERAL-REAGENT), Acetic acid (HOAc, ACS, ≥99.7%, Aladdin), Zirconium(IV) chloride(98%, anhydrous, Alfa Aesar), Zirconyl chloride octahydrate(AR, GENERAL-REAGENT), Terephthalic acid(BDC, RG, 99%, Adamas), 2,5-Dihydroxyterephthalic acid (DOBDC, RG, 99%+, Adamas), N,N-Dimethylformamide(DMF, >99.5%, GENERAL-REAGENT), Nitric acid(HNO₃, AR, GENERAL-REAGENT), Deionized water(DI-water), Ethanol(AR, GENERAL-REAGENT), Dichloromethane (DCM, GENERAL-REAGENT), Petroleum ether (PE, GENERAL-REAGENT), polyvinylpyrrolidone (PVP, Mw~24000, aladdin).

Synthesis of MOF

Synthesis of UiO-66-(OH)₂: 1.1424 g PVP was pre-dissolved in 10 mL DMF. 42 mg ZrCl₄ and 35.7 mg DOBDC were added to 2.7 mL DMF. Then 349 μ L PVP/DMF solution was added and mixed adequately. 2.56 mL acetic acid and 0.1 mL DI water were added subsequently. The well-mixed solution was left undisturbed for 2 hours in the oven of 120 °C. As-synthesized UiO-66-(OH)₂ was centrifuged and washed with DMF twice. The collected UiO-66-(OH)₂ was dispersed in 4 mL DMF for future use.

Synthesis of UiO-66-(OH)₂@UiO-66: 0.15 mmol BDC was added into a mixed solution of 2 mL DMF and 2 mL acetic acid, and then allowed to react at 90 °C for 5 minutes with stirring. 1 mL as-synthesized UiO-66-(OH)₂ suspension in DMF was added and stirred for another 5 minutes. Finally, 1 mL DMF containing 10.5 mg $ZrOCl_2 \cdot 8H_2O$ was added and stirred at 90 °C for 4 hours. The obtained UiO-66-(OH)₂@UiO-66 samples were centrifuged and washed with DMF twice. The collected products were dispersed in 4 mL methanol for future use.

Synthesis of hollow UiO-66 (H-UiO-66) by HNO₃: 1 mL as-synthesized UiO-66-(OH)₂@UiO-66 was centrifuged, dried and dispersed in 5 mL 10 M HNO₃. The suspension was stirred for 2 days. The resulting hollow UiO-66 samples were centrifuged and washed with DMF twice. To remedy defects in hollow MOFs generated during etching, the hollow MOFs were incubated in a DMF solution contain excess ligands. Briefly, about 20 mg hollow sample was dispersed in a 25 mL DMF solution containing 50 mM BDC. After stirring at 100 °C for 3 days, the sample was collected and washed with DMF twice.

Synthesis of ZIF-8⊂H-UiO-66: The ZIF-8 precursor stock solution was first prepared (mol ratio of $Zn(OAc)_2$: HOAc: HMIM:DI-water= 1:3:4.4:100). 8 mg dried H-UiO-66 samples were dispersed with 90 µl precursor solution of ZIF-8 and 1.2 ml ethanol. Dichloromethane (DCM, 2.4 mL) was added to the mixture and sonicated for 5 min to give a clear solution. After adding 6.0 ml petroleum ether (PE), white precipitate was formed. After drying the precipitate in a 120 °C oven, precursors⊂H-UiO-66 was

obtained. Then the sample was soaked in the methanol solution of HMIM (100 mg/ml) overnight to obtain ZIF-8⊂H-UiO-66.

Synthesis of ZIF-67 \subset H-UiO-66: Similarly, Zn(OAc)₂ was replaced by Co(OAc)₂ with the same molar quantity in the preparation of ZIF-67 precursor solution. Precursors \subset H-UiO-66 was synthesized using the same method above. The samples were then soaked in a water solution of HMIM (100 mg/ml) overnight to obtain ZIF-67 \subset H-UiO-66.

Synthesis of ZIF-8¹: 1.05 g Zn(NO₃)₂·6H₂O and 2.34 g HMIM were added into 50 ml methanol at room temperature (RT). After 6 hours, a large amount of white precipitate was produced. The obtained ZIF-8 was centrifuged and washed with methanol twice. The collected products were redispersed in 30 mL methanol for future use.

Synthesis of ZIF-67²: $0.45 \text{ g Co}(\text{NO}_3)_2 \cdot 6\text{H}_2\text{O}$ and 5.5 g HMIM were added into 23 ml DI-water at room temperature (RT). After 6 hours, a large amount of purple precipitate was produced. The obtained ZIF-67 was centrifuged and washed with methanol twice. The collected products were redispersed in 30 mL methanol for future use.

Instrumentation

Powder X-ray diffraction (PXRD) patterns were collected on an X-ray diffractometer (Bruker D8 PHASER) with Cu K□ radiation, operated at 40 kV and 40 mA.

High-resolution scanning electron microscope (HRSEM) images were obtained using a JSM-7800F Prime Scanning Electron Microscopy at 5 kV. The samples were pre-coated with Au for 10 seconds using an SBC-12 sputter coater. **Transmission electron microscope (TEM) images** were taken on a JEM 2100 plus (200 kV) or JEM 1400 plus (120 kV). Powder samples were first evenly dispersed in methanol. Then, a 2.0 μ l solution droplet was added onto a carbon-coated copper grid. **Gas sorption.** N₂ adsorption isotherms were collected by a volumetric gas adsorption analyzer (Quantachrome Instruments Autosorb-iQ-MP-AG). Typically, a 50-80 mg powder sample was loaded in a 6 mm large bulb sample cell and degassed under vacuum at 120 °C for 8 h.



Fig. S1. The SEM images of (A) UiO-66-(OH)₂, (B) UiO-66-(OH)₂@UiO-66, (C) H-UiO-66.



Fig. S2. The PXRD pattern of UiO-66-(OH)₂, UiO-66-(OH)₂@UiO-66, and H-UiO-66.



Fig. S3. N₂ sorption isotherms of neat UiO-66 and H-UiO-66 at 77K



Fig. S4. The TEM image of (A) ZIF-8 precursors⊂H-UiO-66, (B) ZIF-67 precursors⊂H-UiO-66, (C) ZIF-8⊂H-UiO-66, (D) ZIF-67⊂H-UiO-66.



Fig. S5. Pore size distribution of neat MOFs and ZIF-8/67 \subset H-UiO-66 calculated from N₂ adsorption isotherms at 77 K.



Fig. S6. N₂ sorption isotherms of neat MOFs and ZIF-8/67⊂H-UiO-66 at 77K.



Fig. S7. TEM images of (A) mixture of ZIF-8⊂H-UiO-66 and ZIF-8, (B) mixture of ZIF-8⊂H-UiO-66 and ZIF-8 after soaking in 0.5 M gallic acid / ethanol solution at 60 °C for 1 h.

Reference

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